Accepted Manuscript

Doping of metastable Cu3N at different Ni concentrations: Growth, crystallographic sites and resistivity thin sold films

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PII: S0040-6090(17)30906-9

DOI: https://doi.org/10.1016/j.tsf.2017.12.010

Reference: TSF 36384

To appear in: Thin Solid Films

Received date: 7 June 2017

Revised date: 1 December 2017 Accepted date: 12 December 2017

Please cite this article as: Erik Lindahl, Mikael Ottosson, Jan-Otto Carlsson , Doping of metastable Cu3N at different Ni concentrations: Growth, crystallographic sites and resistivity. The address for the corresponding author was captured as affiliation for all authors. Please check if appropriate. Tsf(2017), https://doi.org/10.1016/j.tsf.2017.12.010

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ACCEPTED MANUSCRIPT

Doping of Metastable Cu_3N at Different Ni Concentrations: Growth, Crystallographic Sites and Resistivity

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